

# TEM Sample Preparation & Optical Microscopes

Pablo Mendoza  
Allied High Tech Products, Inc.

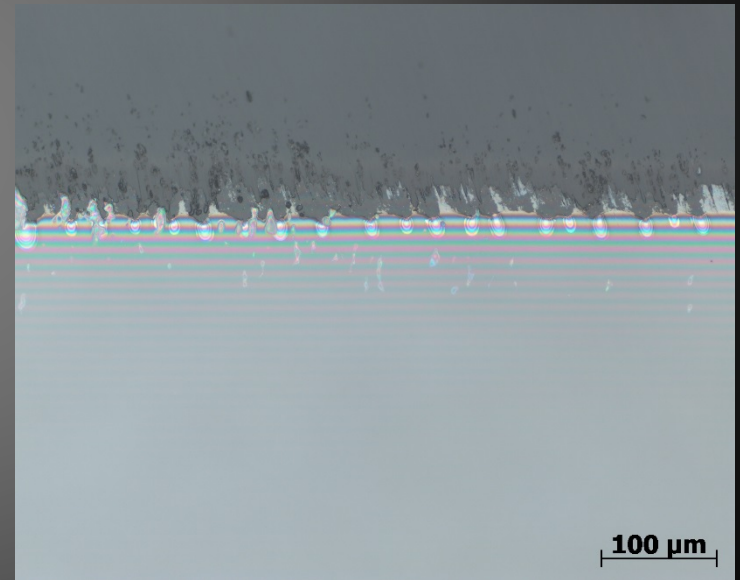
# Introduction

- Materials Engineer
- Allied High Tech Products, Inc.
- 4 years of laboratory experience
- Primary responsibilities:
  - Procedure development for various materials
  - Image Analysis
  - Customer support/training
- Allied High Tech Products, Inc.
- Founded in 1983
- An American Manufacturer and distributor of high quality equipment and consumables for metallographic sample preparation and analysis.
- Zeiss Optical Microscope National Dealer
- Mitutoyo Rockwell and MHT Dealer



# Topics

- Basics
  - What is a TEM sample?
  - Requirements?
  - Methods of preparing TEM samples?
- Mechanical preparation of a TEM sample
  - Preparation process
  - The role of optical microscopy in the sample preparation process
  - Stopping point: Pre-FIB thinning or TEM Wedge?



# What is a TEM Sample?

TEM – Transmission electron microscopy is a microscope technique in which a beam of electrons is transmitted through a specimen to form an image.

TEM Sample – Specimen that is usually ultra thin (<100 nm) to allow electrons to transmit through.



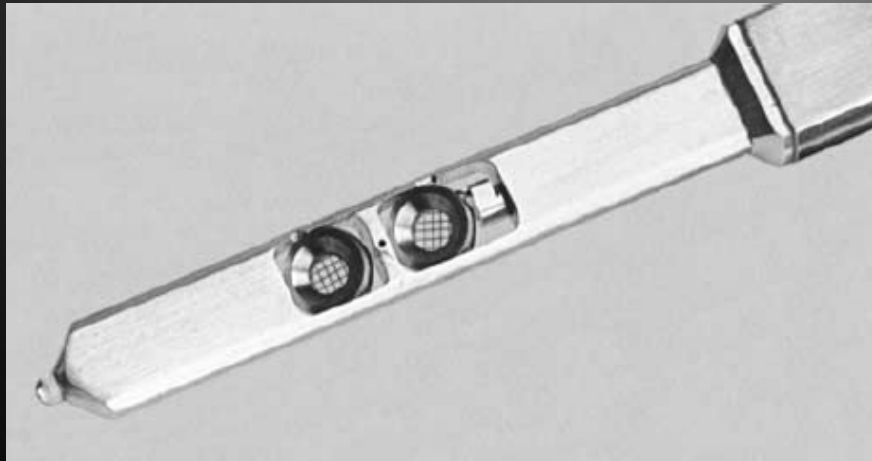
[3] Zeiss HRTEM

# TEM Sample Requirements

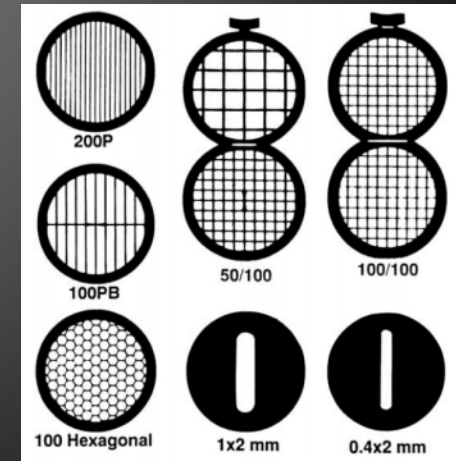
TEM samples must be electron transparent and generally the goal is a sample thickness of  $<100$  nm

Any deformation from thinning process or previous processing must be removed

Small area,  $< 3$  mm or less, to fit various TEM grids and holders



[3] Two-specimen holder with double-tilt

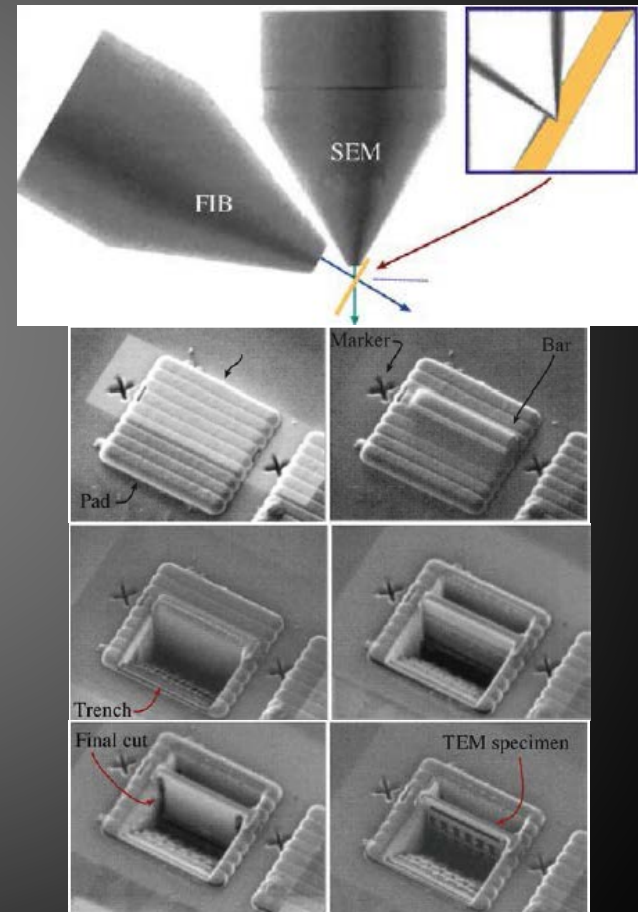


[3] Specimen support grids of different mesh size and shape



# Common Methods of Preparation

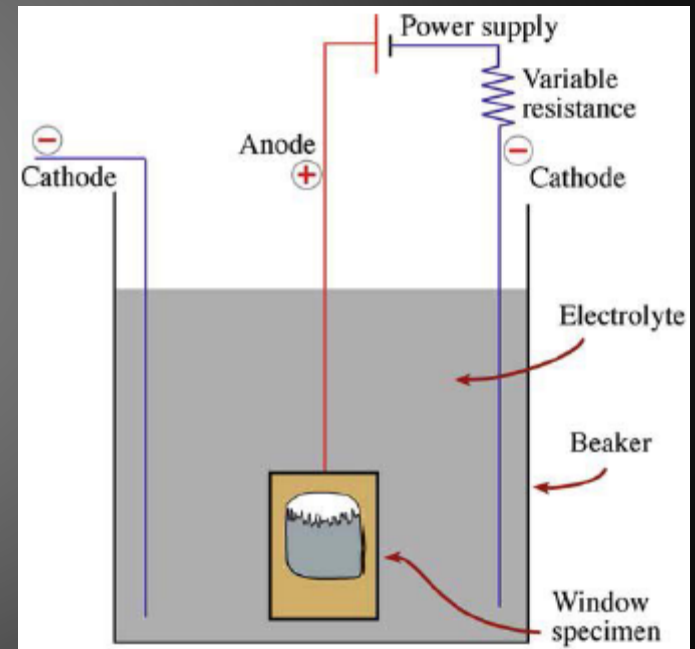
- Ion Milling/FIB – Focused Ion Beam
- Process that involves bombarding a TEM sample with energetic ions or neutral atoms and sputtering material from the sample until it is thin enough to study in the TEM [3].
- The most versatile thinning process that can be used for a wide variety of materials, however very expensive to initially invest in and to run.
- Disadvantage is implantation of source material and amorphous layer is created.
- Most commonly used in semiconductors.



[3] Schematic of a two-beam FIB and stages in making TEM samples using a FIB

# Common Methods of Preparation

- Electropolishing
- Sample is immersed in an electrolyte and then subjected to a direct electrical current. The sample is maintained anodic, with the cathodic connection being made to a nearby metal conductor. [2]
- Anodic dissolution of sample creates polished surface.
- Relatively quick and can produce samples with no mechanical damage, however can only be used for electrically conducting metals and alloys.



[3] The Window Method

# Common Methods of Preparation

- Mechanical Preparation: Can be performed by hand or with the aid of a machine
- Manual: Utilizes hand tools (Tripods) that allow the user to make angle adjustments
- Semi-Automatic: Precision polishers, such as the MultiPrep™ System, with digital indicators and dual micrometers allow:
  - Monitor amount of material removed in real time in 1-micron increments
  - Precise sample tilt adjustments relative to the abrasive plane. Alignment ensures controlled angles.





# Mechanical Preparation

- Advantages

- TEM Wedge capabilities
- All damage removed using the 3x rule
- No foreign material implanted
- With experience it is repeatable and fast
- Lower cost of required equipment
- Decrease milling time and costs

- Disadvantages

- Requires careful handling throughout process
- Greater learning curve than others techniques
- Some samples may require one of the other TEM preparation methods such as metals due to internal strain



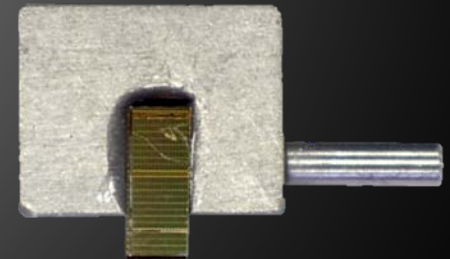
# Preparation

- Area of interest needs to be identified; site-specific or bulk?
- Once determined, sample needs to be prepared
- Preparing TEM samples is essentially performing two cross-sections



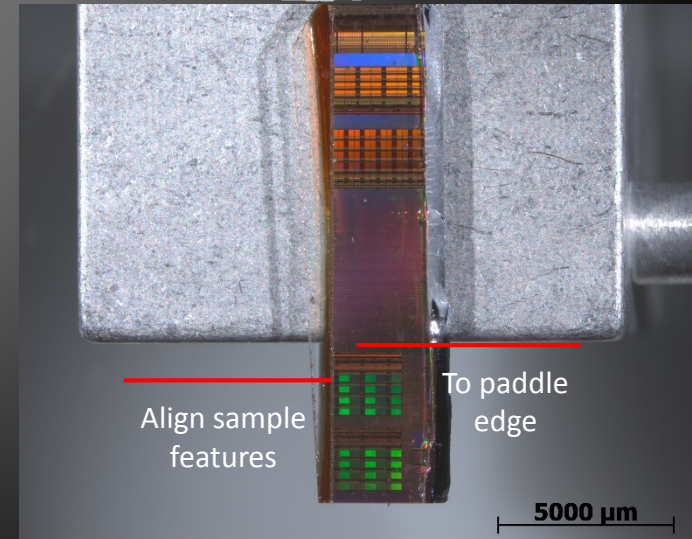
# Thinning First Side

- Sample placed onto a cross-sectioning paddle using mounting wax
- Paddle placed on hot plate to melt wax
- Light pressure can be applied using a cotton-tipped applicator to assist in parallel registration of the sample to the fixture.



# Thinning First Side

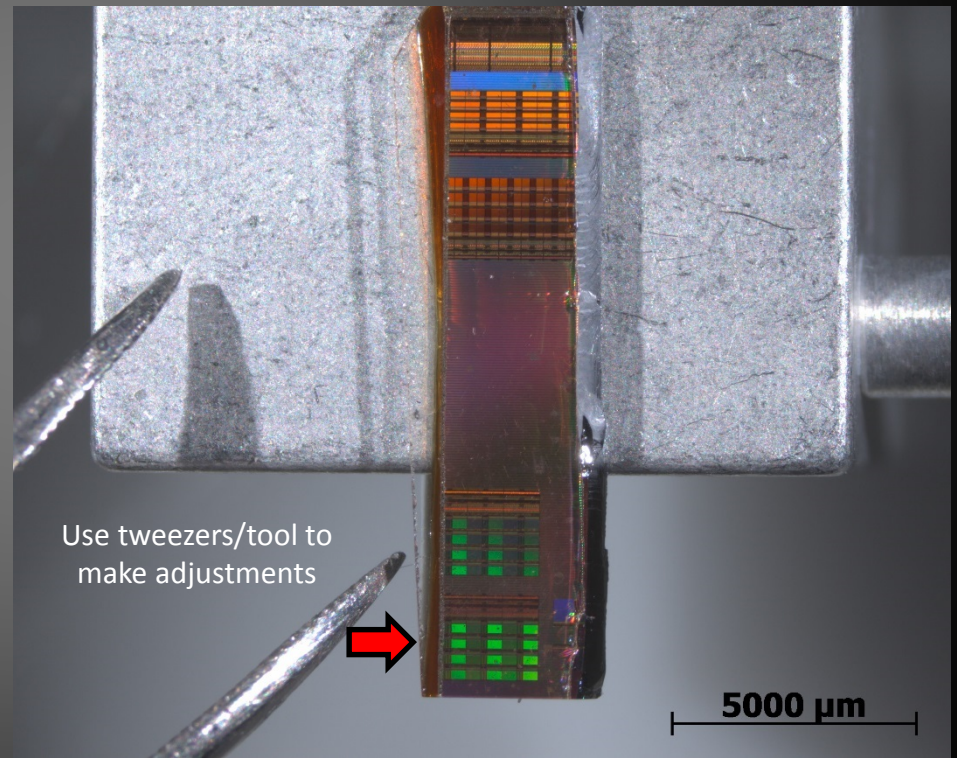
- Stereomicroscope can greatly assist in aligning the sample to the fixture
- Tools such as the MultiPrep™ may have methods of correcting for the angle; however, using a stereomicroscope can minimize the amount of corrections required





# Thinning First Side

- While the paddle is hot, it can be taken to a stereomicroscope
- This allows for sample adjustments before the wax cools and hardens

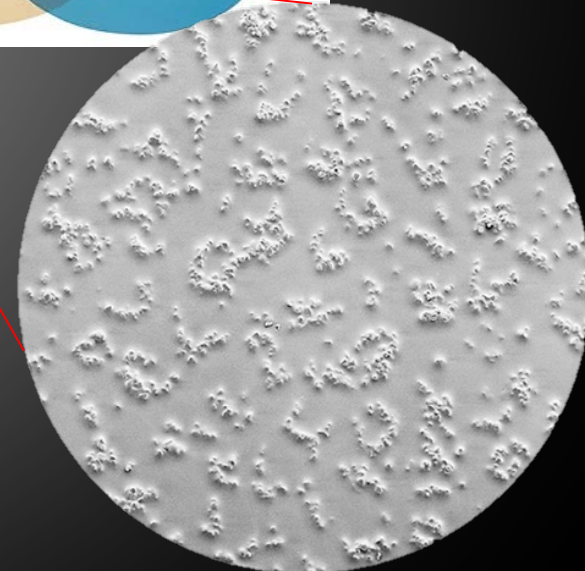
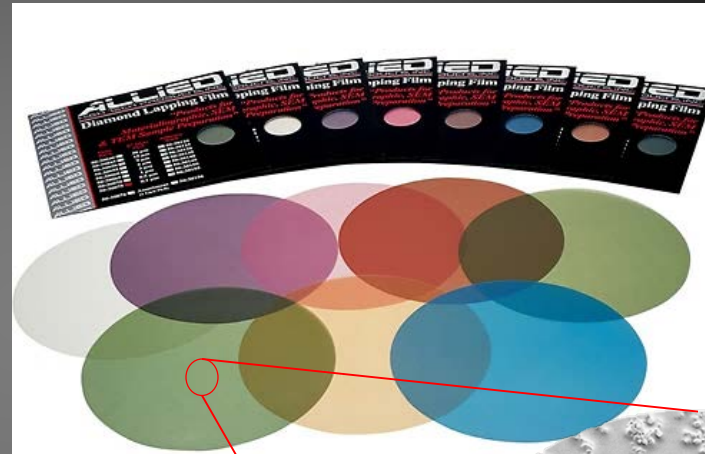


Initial adjustments under microscope



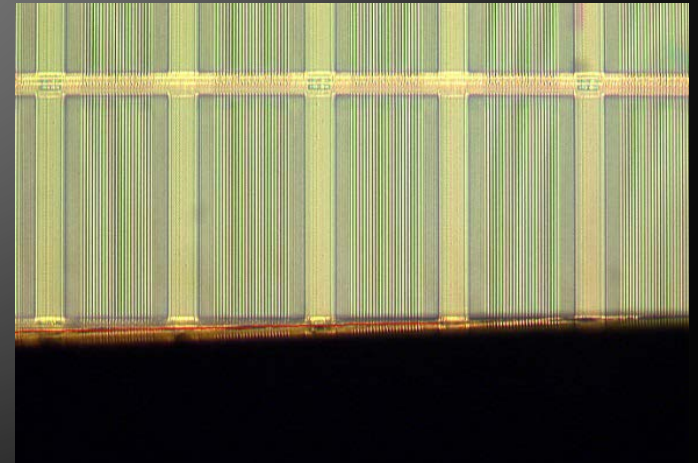
# Thinning First Side

- Lapping films used as abrasive
  - Provide excellent edge retention and maintain coplanarity
  - Typically used for unencapsulated cross-sectioning, TEM preparation, backside polishing, etc.



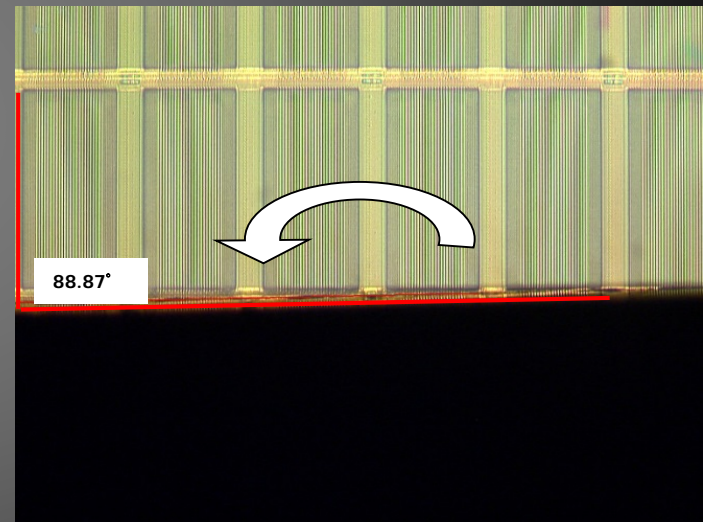
# Thinning First Side

- Initial grinding with a coarse lapping film, such as 30  $\mu\text{m}$ , will give a ground edge
- This ground edge can be used to obtain angle information using optical microscopy



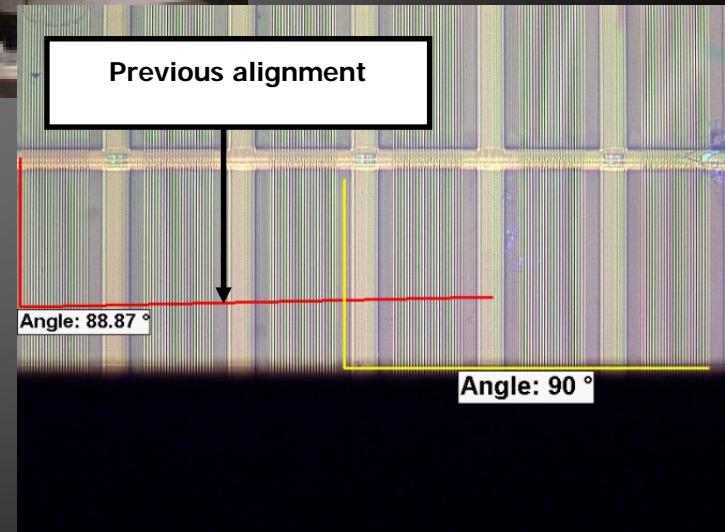
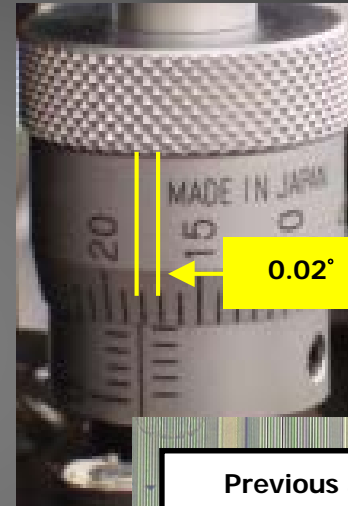
# Thinning First Side

- Compound light microscopes will give the resolution and details needed to perform corrections
- Imaging software can be used to obtain angle measurements



# Thinning First Side

- Angle corrections can be made using the micrometers
- Each tick mark is  $0.02^\circ$
- More material can be removed to obtain a new ground edge
- With the new ground edge, the process can be repeated until an angle correction is no longer necessary



Corrected alignment

# Target: Site-Specific or Bulk?

## Site-Specific

- Particular feature on sample
- Failure Analysis

Must stop at target, without damage from previous steps



## Bulk

- Homogeneous material

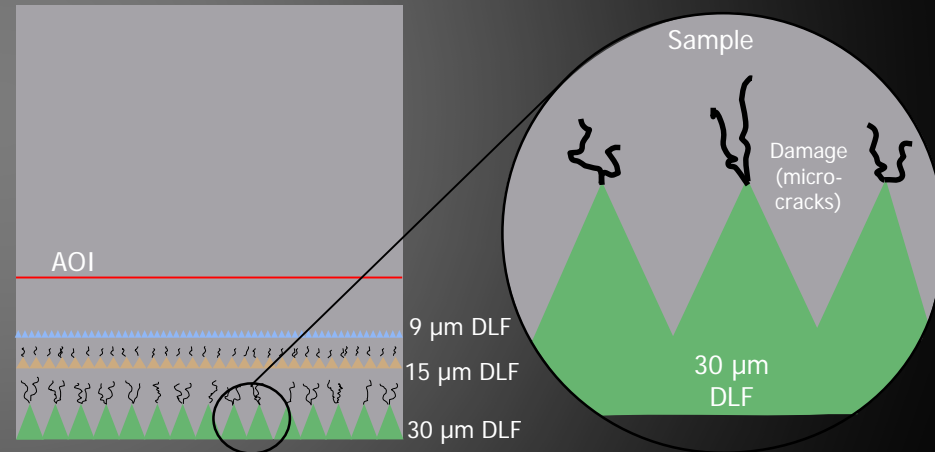
Can stop anywhere, however ensure no damage from previous steps





# 3X Rule

- Damage is introduced into a sample throughout the preparation process.
- This damage is not only represented by a scratch pattern on the surface, but also by smaller micro-cracks that can propagate further into the sample that may not be seen by eye or optical microscopes (A 30  $\mu\text{m}$  lapping film will not cause only 30  $\mu\text{m}$  deep scratches).



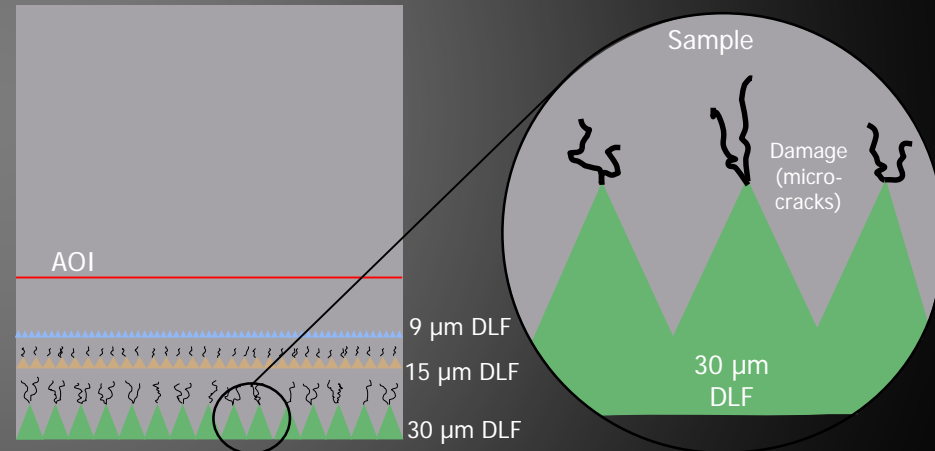
# 3X Rule

- If a 30  $\mu\text{m}$  lapping film is used and it is followed by a 15  $\mu\text{m}$  lapping film step, the 15  $\mu\text{m}$  DLF must remove at least 90  $\mu\text{m}$  of material to completely remove the damage from the 30  $\mu\text{m}$  DLF. Similarly, if a 30  $\mu\text{m}$  DLF is used and it is followed by a 6  $\mu\text{m}$  DLF, then the 6  $\mu\text{m}$  DLF must remove at least 90  $\mu\text{m}$  of material to completely remove the remaining damage.

3X Rule				
Current Step (DLF)	Current Distance from Target	Previous Step	Remove At Least 3x Prev. Step Size	Distance to Target After Current Step
30 $\mu\text{m}$	Vary	N/A	N/A	192 $\mu\text{m}$
15 $\mu\text{m}$	192 $\mu\text{m}$	30 $\mu\text{m}$	90 $\mu\text{m}$	102 $\mu\text{m}$
9 $\mu\text{m}$	102 $\mu\text{m}$	15 $\mu\text{m}$	45 $\mu\text{m}$	57 $\mu\text{m}$
6 $\mu\text{m}$	57 $\mu\text{m}$	9 $\mu\text{m}$	27 $\mu\text{m}$	30 $\mu\text{m}$
3 $\mu\text{m}$	30 $\mu\text{m}$	6 $\mu\text{m}$	18 $\mu\text{m}$	12 $\mu\text{m}$
1 $\mu\text{m}$	12 $\mu\text{m}$	3 $\mu\text{m}$	9 $\mu\text{m}$	3 $\mu\text{m}$
0.5 $\mu\text{m}$	3 $\mu\text{m}$	1 $\mu\text{m}$	3 $\mu\text{m}$	At Target

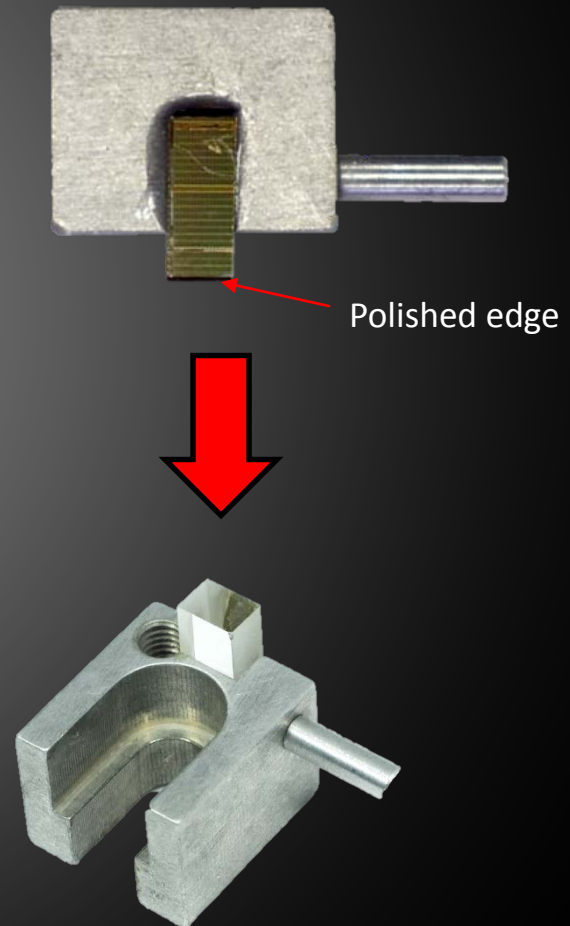
# 3X Rule

- Other materials, such as ductile steels, may only require a “2X Rule”, while fragile, brittle ceramics, where cracks can propagate further into the sample, may require a “4X Rule”.
- The main concept to understand is that no matter what steps follow, all damage introduced by the previous abrasive must be removed to get an accurate representation on the microstructure.



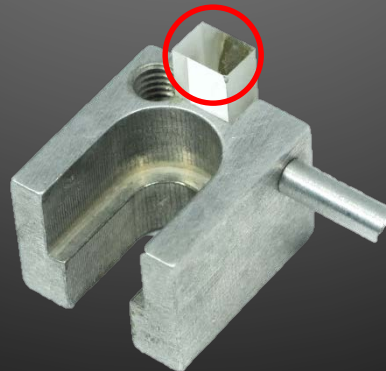
# Flipping Sample

- 2<sup>nd</sup> side needs to be prepared to thin sample
- Previous method using cross-sectioning paddle can't be used; can't overhang sample properly
- TEM paddles with Pyrex<sup>®</sup> inserts are used to continue with the 2<sup>nd</sup> side



# Flipping Sample

- Surface of Pyrex<sup>®</sup> requires grinding
  - Grinding the surface of the Pyrex<sup>®</sup> will align it with that of the platen, ensuring parallelism
- Pyrex<sup>®</sup> can be ground using diamond lapping films
  - 6-3  $\mu\text{m}$  finish is good enough
  - Do not want to polish the surface as having some scratches will help with adhesion



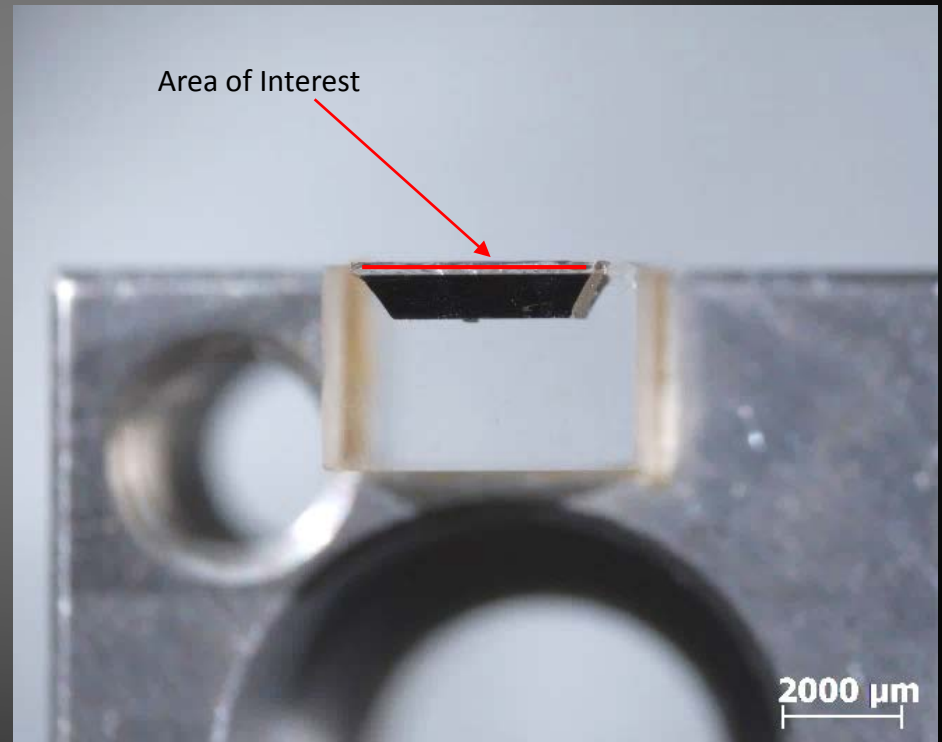


# Site-Specific Orientation

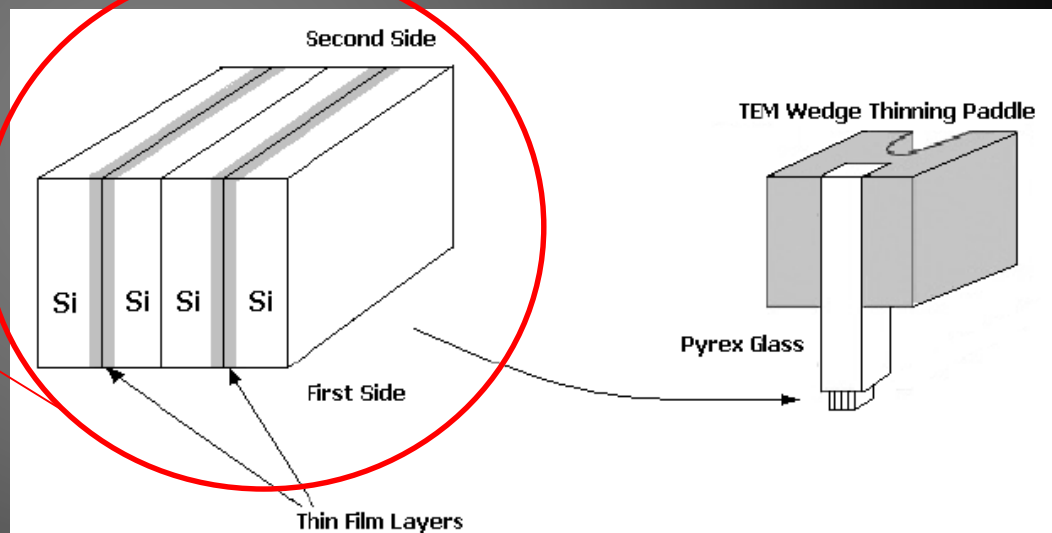
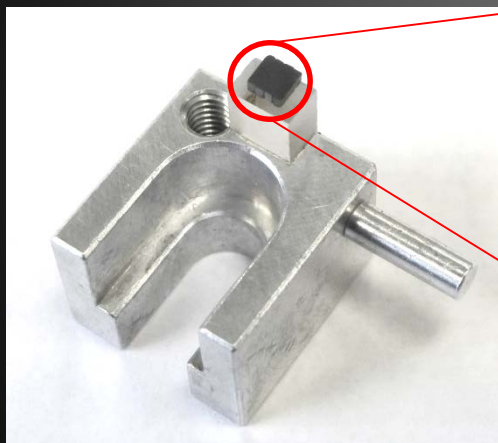


# Site-Specific Orientation

- With site-specific orientation, the area of interest is parallel to the Pyrex<sup>®</sup> edge

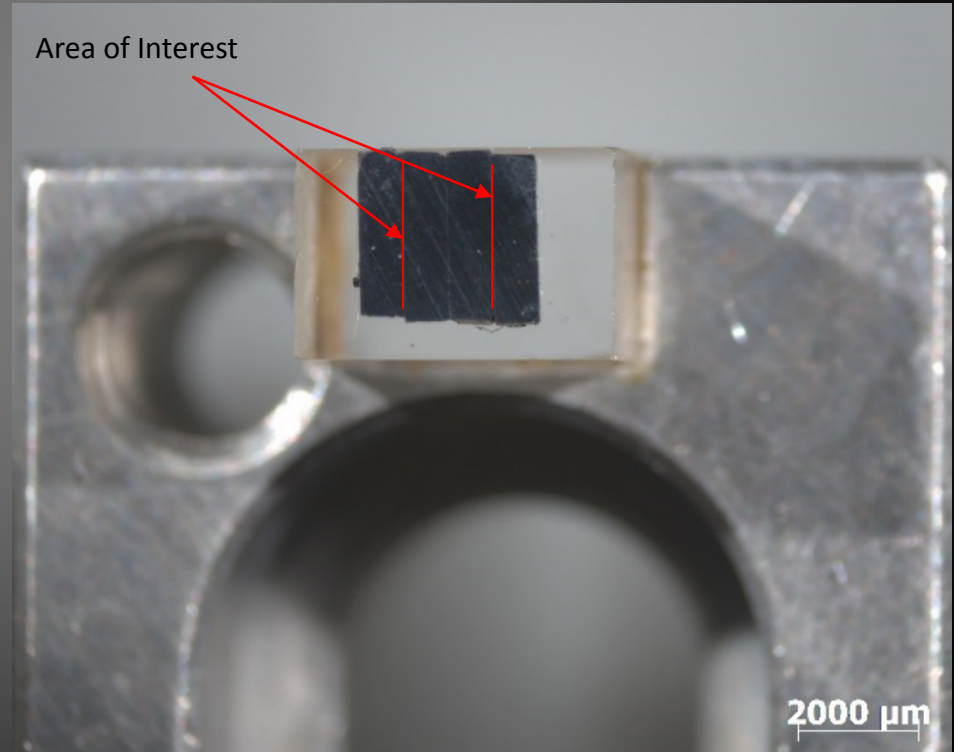


# Bulk Orientation



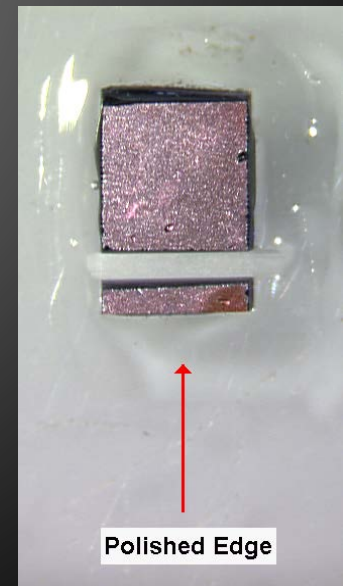
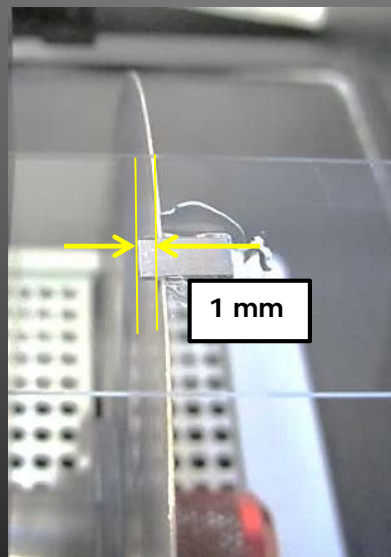
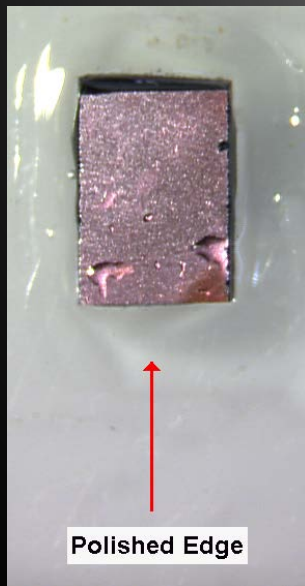
# Bulk Orientation

- With bulk orientation, the area of interest is perpendicular to the Pyrex<sup>®</sup> edge



# Flipping Sample

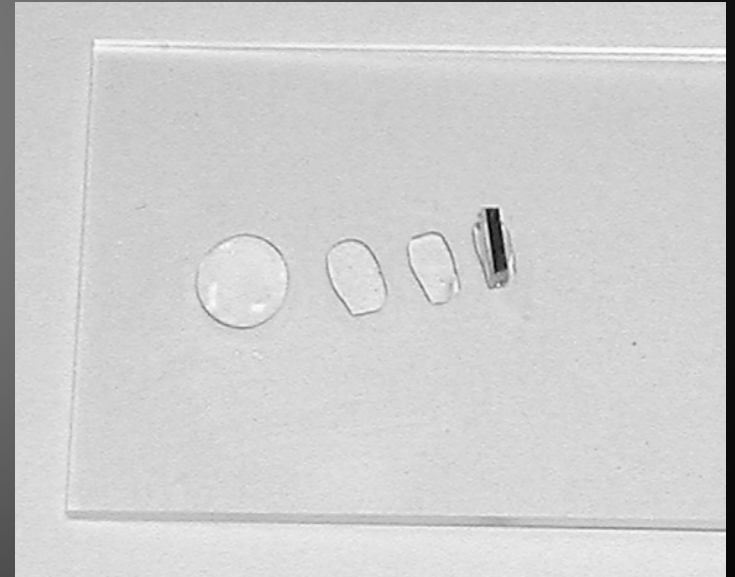
- Sample waxed onto a glass slide
- ~1 mm thick piece sectioned from sample
  - This allows placement onto TEM paddle without risk of the sample breaking off due to being too tall
- Sample should be cleaned to remove abrasive particulates, excess wax, etc.





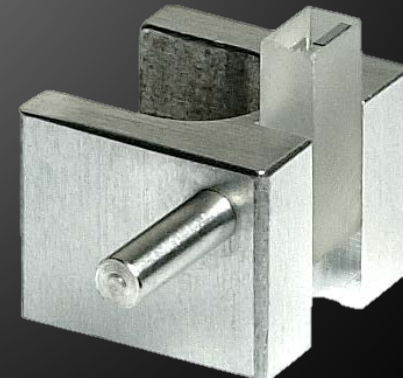
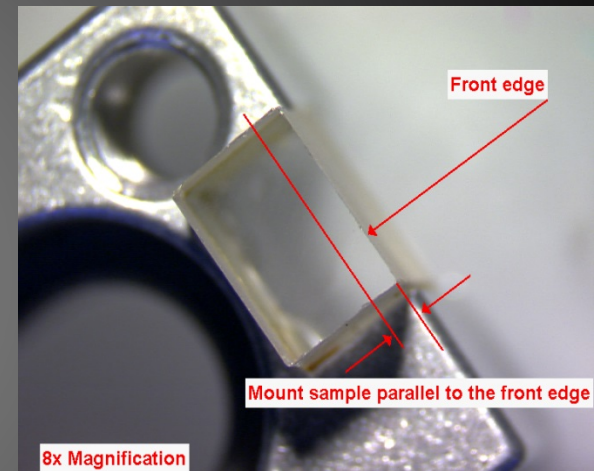
# Flipping Sample

- To ensure stability, a thin, uniform layer of wax needs to be used.
- Wax Bead Method
  - Place sample, polished side down, into wax bead
  - Pick up sample and move over to empty part of glass slide
  - Allow wax to wick away
  - Repeat process 2-3 more times to end up with thin wax layer



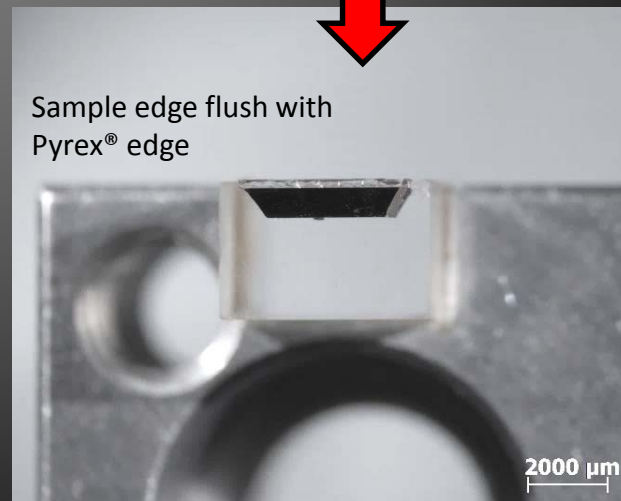
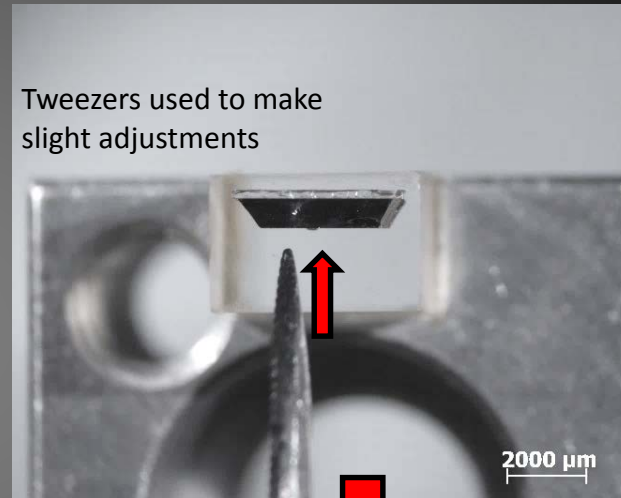
# Flipping Sample

- Polished side placed face down onto the Pyrex<sup>®</sup>
- Positioned near the edge to allow easier thickness measurements later



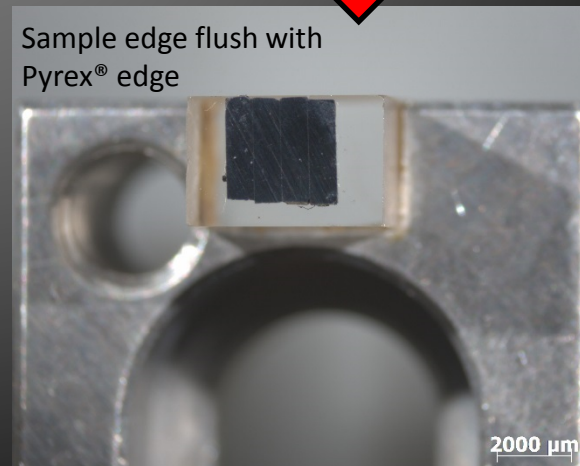
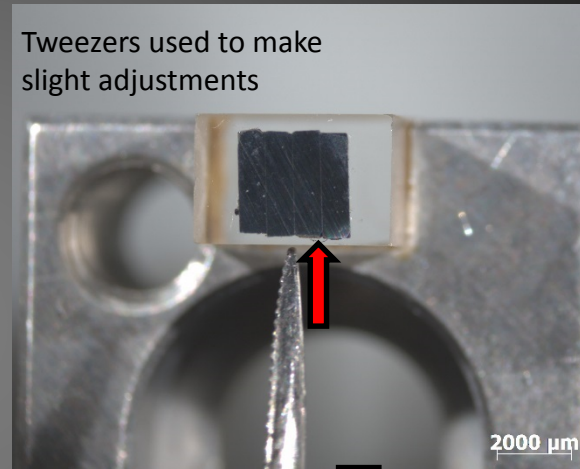
# Flipping Sample

- Stereomicroscope is great for aligning to the edge of the Pyrex<sup>®</sup>



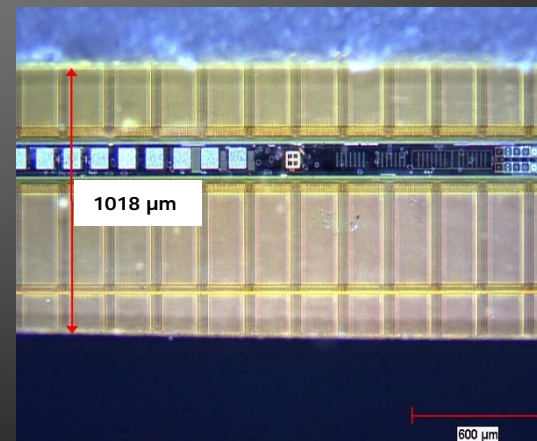
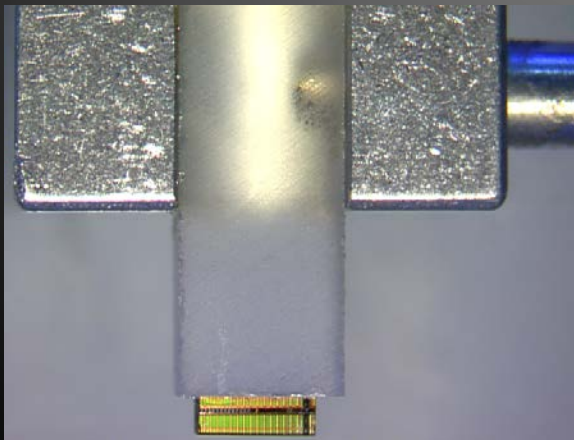
# Flipping Sample

- Stereomicroscope is great for aligning to the edge of the Pyrex®



## Second Side

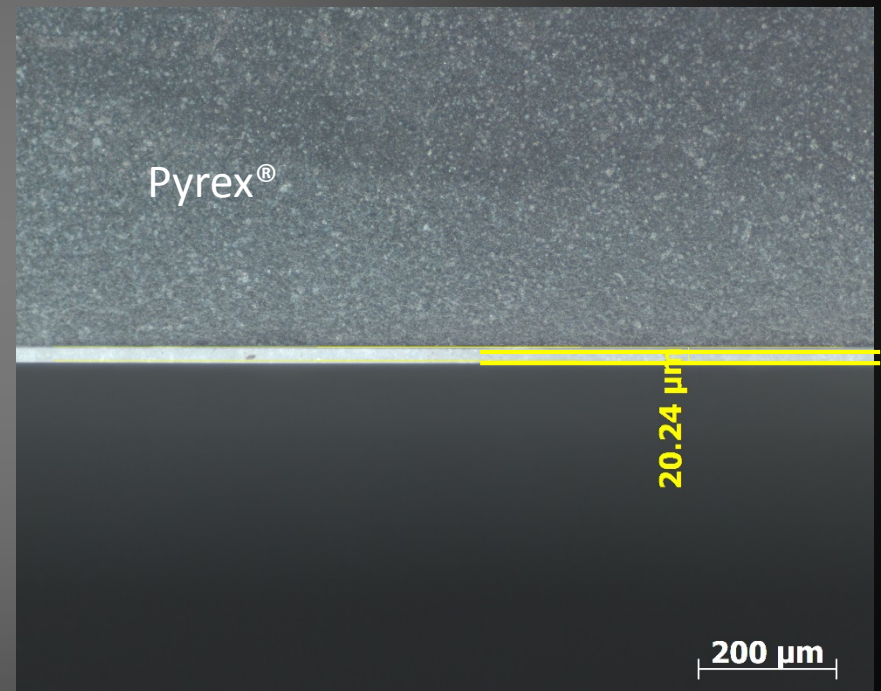
- Second side, whether site specific or not, now has a final target
  - Can lose sample if thin/polish for too long
- Checking sample thickness becomes extremely important if you want to remove all the damage from previous steps
- Certain machines, such as the MultiPrep™ System, may have indicators or other methods to track material removal
  - However, checking progress frequently with an optical microscope is a good way to verify material being removed: trust but verify





## Second Side

- Mounting the sample close to the edge allows for proper focusing on the sample to measure side 1 edge
- Compound scope can give required resolution to view sample thickness and make measurements



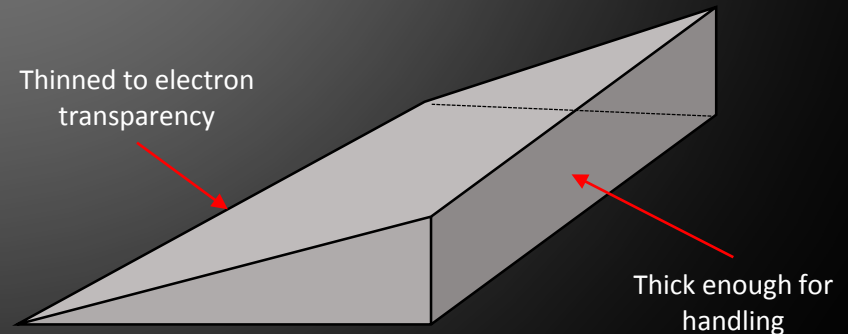
# Goal: Pre-FIB or TEM Wedge?

## Pre-FIB Thinning

- Site-Specific Orientation
- Remove the sample to prepare for FIB thinning
- Sample can be removed by placing paddle into container with acetone (wax dissolves in acetone)
- Filter paper placed around paddle so sample will eventually pop-off and land on paper

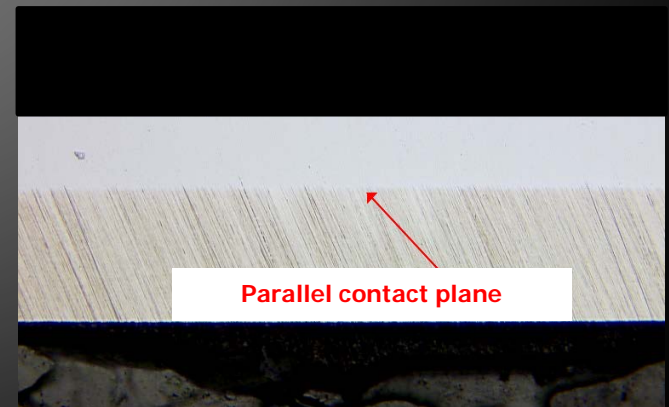
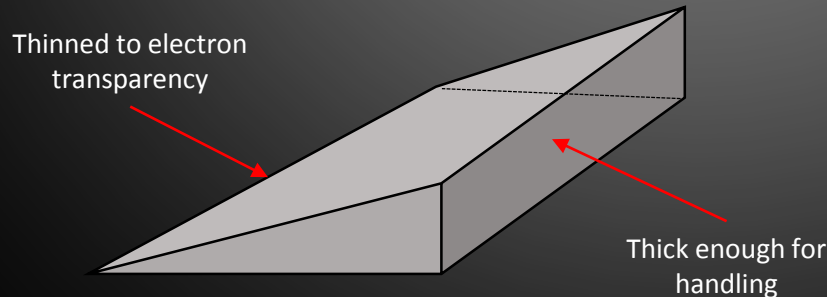
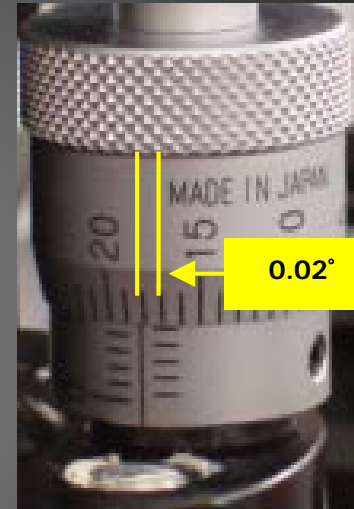
## TEM Wedge

- Bulk Orientation
- Induce an angle to create a wedge sample
- Angle induced will vary depending on the material being prepared



# Inducing Wedge

- Micrometers on MultiPrep™ used to induce an angle on the sample to create a wedge
- Wedge allows for a sample thinned on one edge, with a thick enough edge for handling



# Wedge Polishing

- Certain TEM samples, along with the use of a transmitted light microscope, can display a series of colors in regions less than  $10\text{ }\mu\text{m}$  thick
- Fringes can also occur in regions less than  $2\text{ }\mu\text{m}$  thick
- The thickness that color corresponds to will vary depending on materials; however, some are well documented, such as silicon

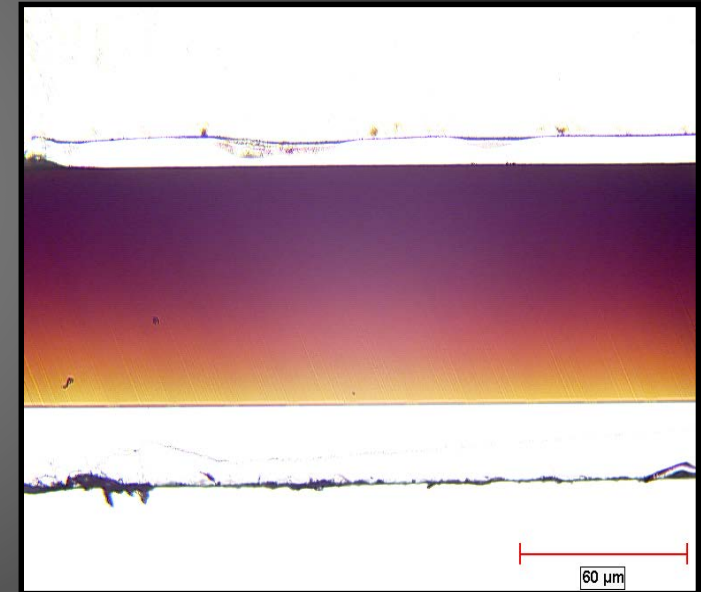


# Wedge Polishing

Color and fringe information can be used to assist in the preparation of TEM samples, as they are a guide to overall progress during a TEM wedge procedure

Si thickness [ $\mu\text{m}$ ]	5	4	3	2	1
Color	Red	Reddish-orange	Orange-red	Orange	Light orange

[4] Correspondence between Si wafer thickness and color of transmitted light

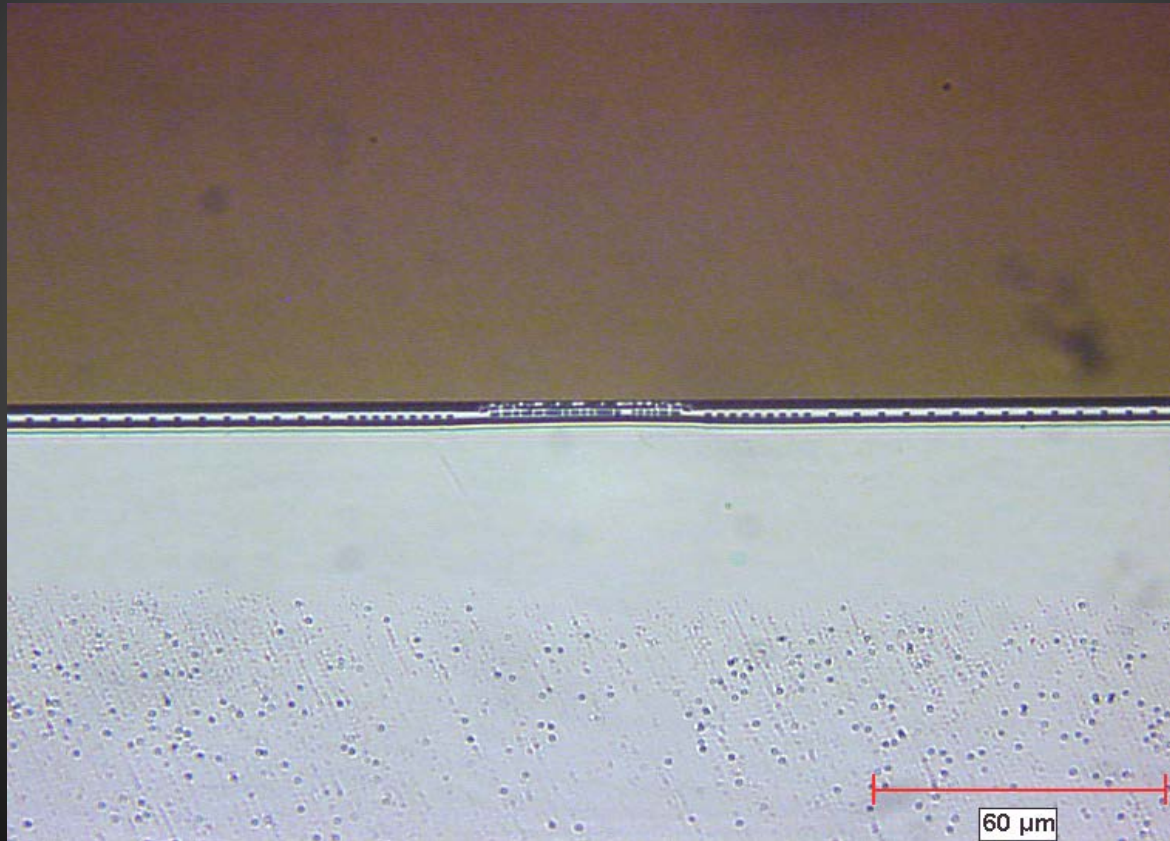




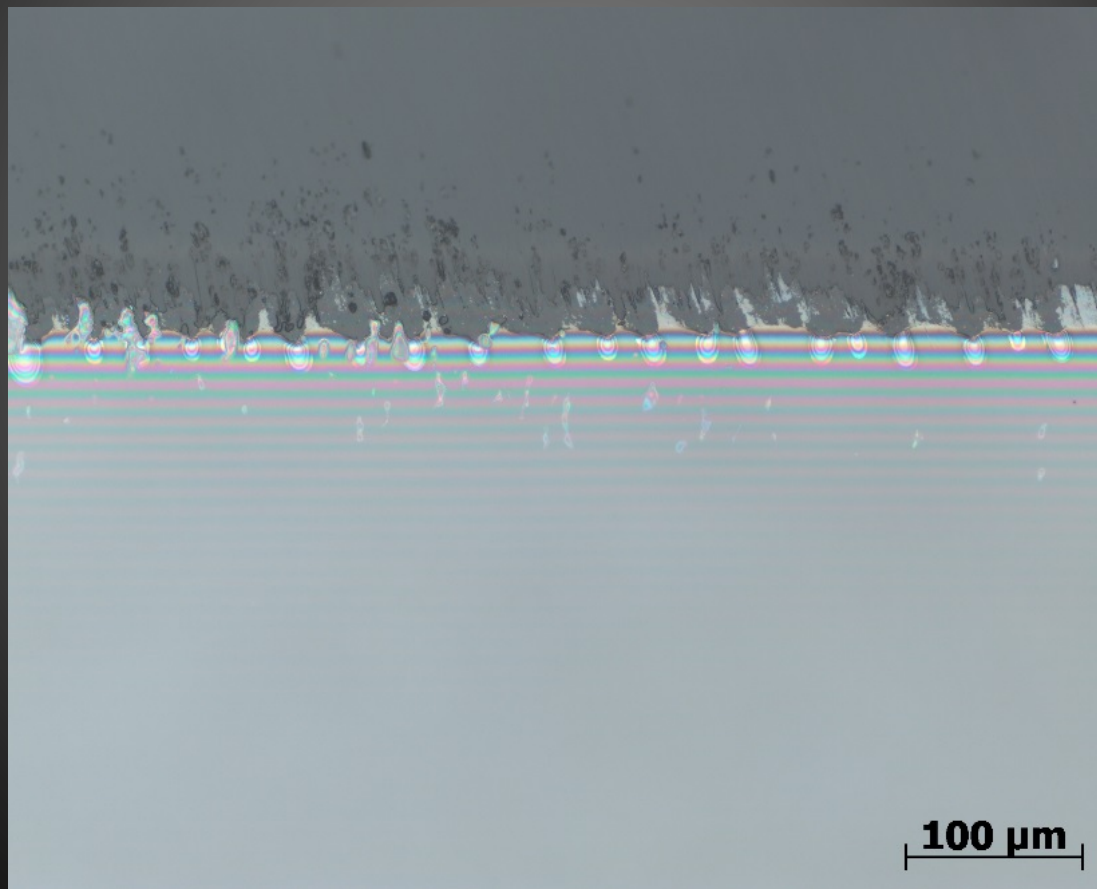
# Wedge Polishing



# Wedge Polishing

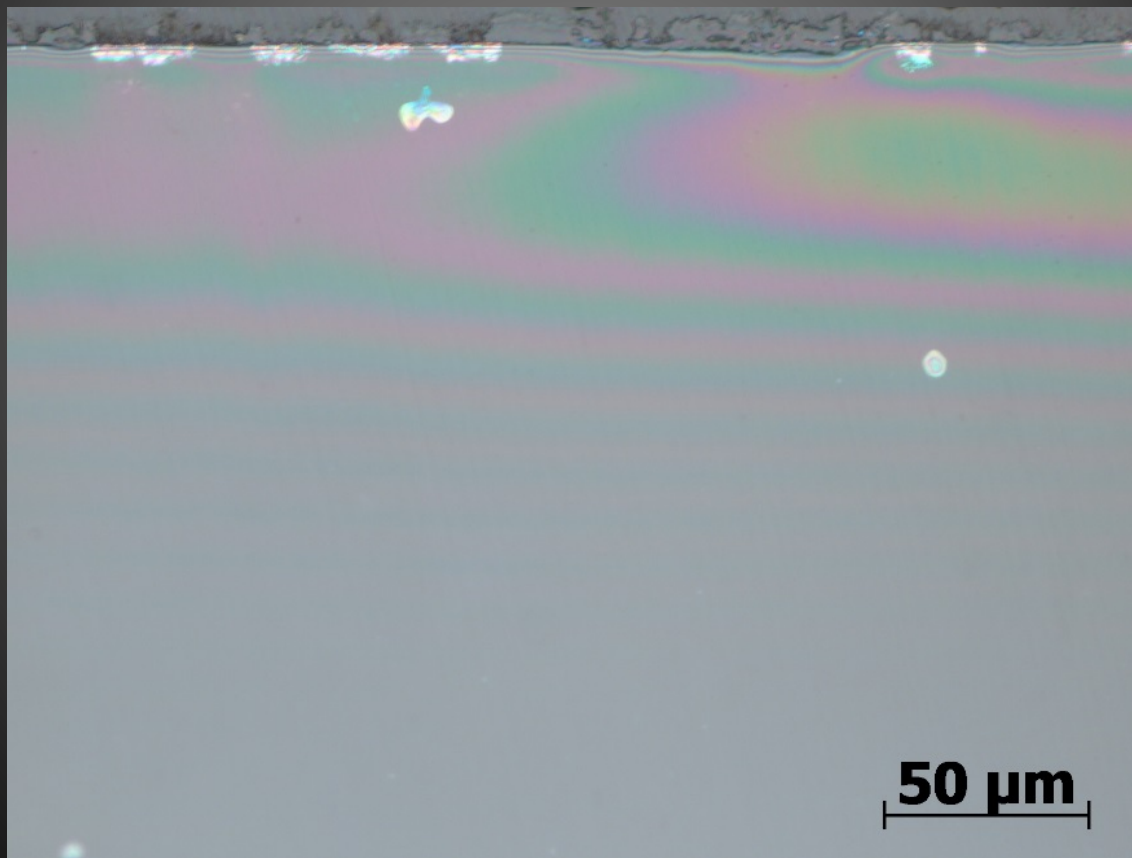


# Wedge Polishing



100 μm

# Wedge Polishing



# References

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# Questions?



**Pablo Mendoza**  
**Materials Engineer, Technical Services**  
**Allied High Tech Products, Inc.**

[pmendoza@alliedhightech.com](mailto:pmendoza@alliedhightech.com)